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NOVEL NANOSTRUCTURES AND METHOD FOR SELECTIVE PREPARATION

FIELD OF THE INVENTION

This invention relates to the field of nanomaterials.

LIST OF REFERENCES

- 5 The following references are considered to be pertinent for the purpose of understanding the background of the present invention:
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The above references will be acknowledged in the text below by indicating their numbers [in brackets] from the above list.

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BACKGROUND OF THE INVENTION

Anisotropic growth of nanomaterials has led to the development of complex and diverse nano-structures such as rods, tetrapods, prisms, cubes and 15 additional shapes. These architectures display new properties and enrich the selection of nano-building blocks for electrical, optical and sensorial device construction. Even greater complexity and new function is introduced into the nanostructure by anisotropic growth with compositional variations. This has been elegantly realized by growing semiconductor heterostructures such as p-n 20 junctions and material junctions in nanowires [1, 2], and in the case of colloidal nanocrystals, in growth of rodlike CdSe/CdS core-shell particles [3] from spherical CdSe core nanocrystals and in complex branched growth.

A process for the preparation of nanocrystalline semiconductors, having rod-like shape of controlled dimensions is described in US 5,505,928 [13] and in 25 WO 03/097904 [4] for especially Group III-V semiconductors, [4]. Nanocrystal particles having core with first crystal structure, and at least one arm with second crystal structure are described in WO 03/054953 [5].

Recently there have been several reports relating to connectivity formation for micron-long quasi-one-dimensional structures such as nanotubes and 30 nanowires [6, 7, 8]. However, wiring of shorter semiconductor nanoparticles

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such as rods and tetrapods, with arm lengths of less than 100 nm has not been achieved yet.

SUMMARY OF THE INVENTION

5 There is a need in the art for new nanostructures having selective, well-defined anchor points grown upon them for use in self-assembly in solution and onto substrates and for electrical or chemical connectivity. Such nanostructures and method for their manufacture are not available to date.

10 Examples of desired nanostructures with well-defined anchor points would be nanoparticles having elongated shapes with different tips e.g. metal tips, grown onto at least one end portion thereof, in a controllable and repeatable manner that would also provide an electrical and/or chemical contact point. The different zones grown onto the nanoparticles end portion would provide well-defined anchor points onto which selective chemistries could be used to generate 15 self-assembled structures of controlled arrangements.

The present invention thus provides in a first aspect nanostructure having at least one elongated structure element comprising a first material, where the elongated structure element bears on at least one of its end portions a second material that differs from the first material in at least one property selected from: 20 electrical conductivity, chemical reactivity (i.e. the property of binding, where "binding" refers to covalent binding, electrostatic interaction or other close association between molecules) and composition.

The first material may be made of metal, semiconductor or insulating material or mixtures thereof. The second material comprises of metal or metal 25 alloy. In such case the second material differs from the first material in electrical conductivity and/or chemical reactivity and/or composition. Alternatively, the second material comprises conductive polymer, semiconductor, insulating material or mixtures thereof. In such case the second material differs from the first material in at least one property selected from electrical conductivity, 30 chemical reactivity and composition.

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In a preferred embodiment the present invention provides new nanoscale structures in which a metal or metal alloy tip (conductive zone) is present on at least one of the end portions of the nanostructure. The novel nanostructures have an elongated shape such as wire, tube, rod, bipod, tripod and tetrapod. The 5 nanostructures of the present invention differ from the nanotubes and nanowires bearing electrodes formed by evaporation, described in references [6-8] above since the electrodes of the prior art were formed on some region of the tube or wire and not on their tips.

Preferably, the nanostructures of the invention have at least one elongated 10 structure element comprising a first material, where said elongated structure element bears on at least one end portion thereof a second material selected from metal and metal alloy. The first and second materials differ in their electrical conductivity and/or chemical reactivity and/or composition.

The term "*material*" in the context of the present invention relates to any 15 solid substance of which the nanostructures of the invention are made, that may be composed of one or more elements or ingredients. Alloys, composites, layered structures and matter formed by chemical union of two or more elements or ingredients are also within the scope of this definition.

The first material mentioned above is selected from semiconductor 20 material, insulating material, metal and mixtures thereof. Preferably, the first material is a semiconductor material selected from Group II-VI semiconductors, Group III-V semiconductors, Group IV-VI semiconductors, Group IV semiconductors, alloys made of these semiconductors, combinations of the semiconductors in composite structures and core/shell structures of the above 25 semiconductors. Even more preferably, the nanostructures are made from Group II-VI semiconductors, alloys made from Group II-VI semiconductors and core/shell structures made from Group II-VI semiconductors. Specific examples of Group II-VI semiconductors are CdSe, CdS, CdTe, ZnSe, ZnS, ZnTe alloys thereof, combinations thereof and core/shell layered-structures thereof.

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The first material is different than the second material in at least one property selected from electrical conductivity, chemical reactivity and composition. The second material may be a metal, metal alloy, insulating material, conductive polymer or semiconductor. Examples of preferred metals 5 are transition metals such as for example Cu, Ag, Au, Pt, Co, Pd, Ni, Ru, Rh, Mn, Cr, Fe, Ti and alloys of such metals. Examples of conductive polymers, including composites and metal doped conductive polymers, are polyaniline, polypyrrole, polythiophene, composites thereof or doped versions thereof. Examples of semiconductors for use as the second material are Group II-VI 10 semiconductors, Group III-V semiconductors, Group IV-VI semiconductors, Group IV semiconductors, alloys made of these semiconductors and combinations of the semiconductors in composite structures.

For nanostructures composed of semiconductor for both first and second materials, such that an elongated nanostructure is made of a first semiconductor 15 that has formed on at least one of its end portions a zone made of a second semiconductor, in such case the second semiconductor material is different than the first semiconductor in at least one of the following properties: electrical conductivity, chemical reactivity, band gap and composition. This kind of nanostructures of the present invention are different from those described in 20 Reference [3] where CdSe dots are surrounded by a CdS shell that is elongated in one direction. The nanostructures described in reference [3] are also grown in a completely different method starting from the dot and growing the shell around it which is then elongated. Examples of suitable semiconductor materials for use as the first or second material are herein described.

25 The present invention provides, in another of its aspects, a method for forming a zone on at least one end portion of a nanostructure, wherein that zone differs from the whole nanostructure, the method comprising: contacting a solution comprising nanostructures composed of at least one elongated structure element, with a solution comprising an agent selected from metal source, metal 30 alloy source, conductive polymer source, insulating material source (e.g. such as

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oxides and organic materials) and semiconductor source, to obtain upon isolation nanostructures bearing at least one zone on said at least one elongated structure thereof that differs from the nanostructure in at least one property selected from: electrical conductivity, chemical reactivity and composition.

- 5 In a preferred embodiment, the method of the invention comprises: contacting a solution comprising nanostructures composed of at least one elongated structure element, with a solution comprising metal source or metal alloy source, to obtain upon isolation nanostructures bearing at least one zone comprising metal or metal alloy on said at least one elongated structure thereof,
- 10 where the metal or metal alloy zone differs from the whole elongated element in electrical conductivity and/or chemical reactivity and/or composition.

The method is carried out in solution, at a temperature between about - 40°C to about 400°C, preferably between about 10°C to about 80°C, more preferably between about 20°C to about 30°C and even more preferably at room 15 temperature.

According to a preferred embodiment the reaction is carried out in the presence of at least one of the following agents in addition to said nanostructures and metal source of conductive second material: electron donor, surfactant and stabilizer. In a specific embodiment the same agent may function as electron 20 donor, and/or surfactant and/or stabilizer.

The nanostructures used in the method of the invention have an elongated shape, for example of rods, wires, tubes, or in branched form. More preferably the nanostructures have an elongated shape such as for example nanorods and branched shape such as bipods, tripods, tetrapods and the like. The term 25 "nanorod" or "rod" as used herein is meant to describe a nanoparticle with extended growth along the first axis while maintaining the very small dimensions of the other two axes, resulting in the growth of a rod-like shaped nanocrystal of very small diameter in the range of about 1 nm to about 100 nm, where the dimensions along the first axis may range from about several nm to about 1 30 micrometer. The term "tetrapod" is meant to describe a shape having a core from

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which four arms are protruding at tetrahedral angles. In the case of nanorods, the resulting structures after treating them with the metal or metal alloy source are shaped as "nano-dumbbells".

The nanostructures have an elongated shape or even a branched shape and 5 serve as a template at the nanometer level for the deposition of a conducting material, and as it will be described and exemplified herein below, the deposition is accomplished in a controllable manner on at least one end portion of the elongated elements of the nanostructures.

The nanostructures are made of a first material comprising semiconductor 10 material, insulating material, or mixtures thereof. Preferably, the nanostructures are made of semiconductor material selected from Group II-VI semiconductors, such as for example CdS, CdTe, ZnS, ZnSe, ZnO, HgS, HgSe, HgTe and alloys (e.g. CdZnSe); Group III-V semiconductors such as InAs, InP, GaAs, GaP, InN, 15 GaN, InSb, GaSb, AlP, AlAs, AlSb and alloys (e.g. InAsP, CdSeTe, ZnCdSe, InGaAs and the like); Group IV-VI semiconductors such as PbSe, PbTe and PbS and alloys; and Group IV semiconductors such as Si and Ge and alloys. Additionally, combinations of the above in composite structures consisting of sections with different semiconductor materials, for example CdSe/CdS or any other combinations, as well as core/shell structures of different semiconductors 20 such as for example CdSe/ZnS core/shell nanorods, are also within the scope of the present invention.

The nanostructures may also be made of an insulating material such as for example oxides and organic materials or, alternatively the nanostructures are made of metals. Examples of oxides are silicon oxide, titanium dioxide, zirconia: 25 Metals include Au, Ag, Cu, Pt, Co, Ni, Mn and the like, and various combinations and alloys thereof. Organic materials suitable for use in the nanostructures are for example polymers.

The metal or metal alloy source used in the method of the present invention for the fabrication of the conductive zone at the end portion of an 30 elongated structure element preferably comprises a transition metal or mixture of

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such metals. A variety of metals may be used. This includes noble metals such as Cu, Ag, Au, or other transition metal elements such as Pt, Co, Pd, Ni, Ru, Rh, Mn, Cr, Fe, Ti and the like. The metal growth procedure is done by using a proper metal salt source, for example AuCl₃ for Au growth, Ag(CH₃COO) for 5 silver growth, Cu(CH₃COO)₂ for Cu growth, PtCl₄ or Pt(acetylacetone) for Pt growth, Ni(cyclooctadiene)₂ for Ni growth, Co₂(CO)₈ or CoCl₂ for Co growth, and Pd(NO₃)₂ for Pd growth.

The metal salts are dissolved in a proper organic solvent such as hydrocarbons, e.g. hexanes, cyclohexanes, etc., aromatic solvents e.g. toluene, 10 etc., using a proper surfactant and/or stabilizer that stabilizes the nanostructures and the metal salt by preventing aggregation. The organic solvent used in the method of the present invention is one capable to solubilize both the nanostructure and the metal source.

Examples of surfactants are cationic surfactants such as ammonium salts, 15 alkyl pyridinium and quaternary ammonium salts. More specific examples are tetrabutylammonium borohydride (TBAB), di-dodecyldimethylammonium bromide (DDAB), cetyltrimethylammonium bromide (CTAB), and salts of quaternary ammonium with acetate group ions such as acetate group ions, pivalate, glycolate, lactate and the like.

20 Stabilizer compounds used in the method of the invention are such compounds capable to coordinate to the nanostructure surface and/or the metal particle surface and hence prevent aggregation of the nanostructures. Examples of stabilizers are aliphatic amines, e.g. hexadecylamine, dodecylamine, octylamine , alkylthiols, e.g. hexane thiol, decylthiol, dodecylthiol, etc. and 25 carboxylic stabilizers such as myristic acid, palmitic acid and citrate.

The metal or metal alloy salt is first dissolved in an organic solvent comprising a surfactant and a stabilizer to give a solution which is subsequently added in a controllable manner and a suitable temperature to the nanostructures solution.

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When an electron source is desired in the method of the invention, an electron donor compound may be used. Examples of electron donors are organic compounds, such as aliphatic amines, hydrides such as sodium borohydride and the like, ascorbic acid and other reducing agents. A stabilizer can also serve as 5 an electron donor, for example an aliphatic amine. A surfactant can also serve as an electron donor, for example tetrabutylammonium borohydride (TBAB). According to another example the electron source is obtained from an electron beam device. Alternatively, one may use electromagnetic radiation such as that from a light source including a lamp or laser in order to excite the nanoparticles 10 or the metal source.

In another preferred embodiment , the present invention provides a method for forming in solution medium an electrically conductive zone on a nanostructure having at least one elongated structure, the method comprising: contacting an organic solution comprising semiconductor nanostructures 15 composed of at least one elongated structure element, with an organic solution comprising a metal or metal alloy source, a stabilizer and/or surfactant to obtain upon precipitation semiconductor nanostructures bearing at least one electrically conductive zone on said at least one elongated structure thereof. Preferably, the nanostructures used in the method of the invention are in the form of nanorods, 20 tetrapods or any other branched structure and are made of elements of Group II-VI, alloys of such elements or core-shell layered structures thereof.

The method of the present invention provides new functionalities to the nanostructures, the most important of which are the formation of reactive anchor points for directed self assembly and for electrical or chemical connectivity. The 25 selective tip growth of metal contacts provides the route to an effective wiring scheme for soluble and chemically processable nanostructures with branched shapes. This would allow to fully realize the potential of miniaturization of devices using such nano-building blocks, while employing the powerful principles of self-assembly to connect them to the 'outside' world.

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Nanostructures obtainable by the method of the invention are within the scope of the invention.

Electronic and optical devices comprising the nanostructure of the invention or into which the nanostructure of the invention is integrated are also 5 within the scope of the invention. Non-limiting examples are electrodes, transistors e.g. field effect transistor, memory devices, and the like and self assembled constructs comprising a plurality of nanostructures, wherein each nanostructure is linked to another nanostructure in the construct through its conductive zone.

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BRIEF DESCRIPTION OF THE DRAWINGS

In order to understand the invention and to see how it may be carried out in practice, preferred embodiments will now be described, by way of non-15 limiting example only, with reference to the accompanying drawings, in which:

Fig. 1 illustrates TEM (Transmission Electron Microscopy) images A-D showing growth of Au onto CdSe quantum rods of dimensions 29x4 nm (length x diameter). Fig. 1A shows the rods before Au growth, Fig. 1B shows selective Au growth of about 2.2 nm; Fig. 1C shows selective Au growth of about 2.9 nm; and 20 Fig. 1D shows selective Au growth of about 4 nm.

Fig. 2A illustrates the EDS (Energy dispersive X-ray spectroscopy) spectrum of a gilded CdSe rod sample. The relative atom percentage of Au:Cd:Se is 18%:42%:40%.

Fig. 2B illustrates a powder X-ray diffraction comparing CdSe rods before 25 (1), and after (2) Au growth.

Figs. 2C and D illustrate HRTEM images of a single nano-dumbbell and a nano-dumbbell tip, respectively. The CdSe lattice for the rod in the center, and Au tips at the rod end portions, can be identified as marked.

Fig. 3 illustrates TEM images A-H showing growth of Au on tips of 30 various CdSe quantum rods and CdSe tetrapods. Figs. 3A and 3B: 12x4 nm

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quantum rods before and after Au growth, respectively. Figs. 3C and 3D: 29x4 nm quantum rods before and after Au growth, respectively. Figs. 3E and 3F: 60x6 nm quantum rods before and after Au growth, respectively. Au growth on CdSe tetrapods showing a general view is presented in Fig. 3G and higher magnification image for one tetrapod is presented in Fig. 3H.

Fig. 4A illustrates the absorption spectra for CdSe/ZnS core/shell nanorod sample with varied Au tip size compared to the original rod template, where Au tip size is indicated for each trace. Spectra are offset vertically for clarity. Inset shows TEM image of the sample after Au growth (scale bar is 50 nm).

Fig. 4B illustrates the photoluminescence (PL) spectra for CdSe/ZnS core/shell nanorod sample with varied Au tip size compared to the original rod template, where Au tip size is indicated for each trace. Traces were multiplied by 25, 50 and 50 for the 2 nm, 3.2 nm, and 4.5 nm Au tips, respectively, for clarity. Inset shows a plot of relative PL yield for template (Φ_0) over Au-rod (Φ), versus Au ball size. Measurements were performed for rod solutions in a sealed cuvette under Ar using the 454 nm line of an Ar-ion laser with intensity of 100 mW. Fluorescence was collected using identical conditions for all solutions in a right angle configuration with a spectrograph/CCD setup, with 500 ms integration time.

Fig. 5 shows sizing histograms for gilded rods shown in Fig. 1. Histograms for rod diameter (Fig. 5A), length (Fig. 5B) and Au diameter (Fig. 5C) are shown for the four samples: 1. Original 29x4 nm rods, 2. Rods (10 mg) after treatment with 4 mg AuCl_3 , 25 mg DDAB and 40 mg dodecylamine. 3. Rods (10 mg) after treatment with 8 mg AuCl_3 , 50 mg DDAB and 90 mg dodecylamine. 4. Rods (10 mg) after treatment with 13.5 mg AuCl_3 , 100 mg DDAB and 160 mg dodecylamine.

Fig. 6 illustrates TEM of product from mixture of rods with AuCl_3 and DDAB without dodecylamine, Fig. 6A. before exposure to the TEM electron beam – aggregated rods are seen. Fig. 6B. after exposure to the TEM electron beam – Au patches appear on the rods.

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Fig. 7 shows conductive atomic force microscopy current image of single nano-dumbbell measured at a sample bias of 2V. Higher conductance through the Au tips is observed, as seen also by the current cut taken along the rod (along plotted line). In the inset, a TEM image with the same scale of a Au-rod is shown for comparison.

Fig. 8 shows the self assembly of nano-dumbbells into chains formed by adding hexane dithiol bifunctional linker to a solution of nano-dumbbells.

Fig. 9 illustrates TEM images A-D showing one-sided growth of Au on tips of CdSe quantum rods having different sizes: Fig. 9A – 18x3.5nm; Fig. 9B – 25x4nm; Fig. 9C – 50x4nm; Fig. 9D – the same as (C) with different gold tip size.

DETAILED DESCRIPTION OF THE INVENTION

The method is exemplified hereinbelow with reference to selective growth 15 of metal tips onto semiconductor nanorods and tetrapods.

In a method for selective growth of contacts made of gold, AuCl_3 was dissolved in toluene by use of di-dodecyldimethylammonium bromide (DDAB) and dodecylamine, and the resulting solution was added to a toluene solution comprising of colloidal grown nanorods or tetrapods. The method is exemplified 20 for the prototypical CdSe nanocrystal system that is highly developed synthetically and widely studied for its size and shape dependent properties.

CdSe rods and tetrapods of different dimensions (see below), were prepared by high temperature pyrolysis of suitable precursors, in a coordinating solvent containing a mixture of trioctylphosphineoxide (TOPO), and of 25 phosphonic acids [9]. In a typical Au growth reaction, a gold solution was prepared containing 12 mg AuCl_3 (0.04mmol), 40 mg of DDAB (0.08mmol) and 70 mg (0.37mmol) of dodecylamine in 3 ml of toluene and sonicated for 5 minutes at room temperature. The solution changed color from dark orange to light yellow. 20 mg (1×10^{-8} moles of rods, where each rod has about 7000 CdSe 30 units) of CdSe quantum rods with 29X4nm size, were dissolved in 4 ml toluene

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in a three neck flask under argon. The gold solution was added drop-wise over a period of three minutes. During the addition, carried out at room temperature, the color gradually changed to dark brown. Following the reaction, the rods were precipitated by addition of methanol and separated by centrifugation. The 5 purified product could then be redissolved in toluene for further studies.

Fig. 1 presents transmission electron microscopy (TEM) images showing growth of Au onto CdSe quantum rods of dimensions 29x4 nm (length x diameter). Fig. 1A shows the rods before Au growth, while in Figs. 1B-D, selective Au growth onto the rod tips is clearly identified as the appearance of 10 points with enhanced contrast afforded by the higher electron density of the Au compared with CdSe. The rods now appear as 'nano-dumbbells'. Moreover, by controlling the amount of initial Au precursor, it is possible to control the size of the Au tips on the nano-dumbbell end portions, from ~2.2 nm in Fig. 1B, to ~2.9 nm in Fig. 1C, to ~4.0 nm in Fig. 1D as summarized in Table 1. The procedure 15 clearly leads to the growth of natural contact points on the tips of the rods.

Table 1

Sample	NC's ¹ amount(mg)	DDA ² amount(mg)	DDAB ³ amount(mg)	AuCl ₃ amount(mg)	Rods size (Lx D)nm	Gold ball size (nm)
1	-	-	-	-	29 x 4 nm	(original rod)
2	10 mg	40 mg	25 mg	4 mg	25.6 x 3.3 nm	2.22 nm
3	10 mg	90 mg	50 mg	8 mg	23.9 x 3.4 nm	2.9 nm
4	10 mg	160 mg	100 mg	13.5 mg	20.8 x 3.2 nm	4 nm

¹ NC - nanocrystals

20 ² DDA – dodecylamine

³ DDAB – didodecyldimethylammonium bromide

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An additional observation from the analysis of ~200 particles per sample is that the overall rod length becomes shorter upon Au growth, and there is also a decrease in the average diameter of the rods, (Table 1 and Fig. 5 for the complete sizing histograms). Control experiments with the DDAB and dodecylamine without AuCl_3 were carried out and also in that case the average rod dimensions decreased, implying that reduction of rod size is perhaps related to dissolution of rods in the presence of DDAB and not to the Au growth.

Several structural and chemical characterization methods have been carried out in order to verify the material content and structure of the gold on the rod tips. Fig. 2A shows EDS analysis of a micron area of rods after growth and the appearance of Au in the gilded (i.e. goldenized) and purified rod sample is clear. The powder X-ray-diffraction pattern for the 29x4 nm rod sample comparing the rods before and after gold growth is shown in Fig. 2B. The appearance of the Au (111), (200) and (220) peaks following Au growth is evident, demonstrating crystalline Au is formed on the tips.

Further evidence for Au growth onto single rods, is provided by HRTEM (high resolution TEM) studies of the nano-dumbbells. Fig. 2C shows a HRTEM image of a single rod after gold treatment. The lattice image for the rod part composed of CdSe corresponds to growth of rods along the CdSe <001> axis. The Au is discerned once again as the region at the end portion with enhanced contrast and the gold lattice is also shown in Fig. 2D.

Relating to the interface at the Au-CdSe, it is suggested that Au-Se bonds are formed, analogous to the known AuSe material [10]. This means that the interface is formed with covalent chemical bonds between the metal and the semiconductor and hence can be expected to provide good electrical connectivity.

The method for selective Au growth could be easily expanded and applied to rods of arbitrary dimensions, and to tetrapods, as well as to growth of other metals and to rods made of various semiconductor materials.

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Fig. 3 shows TEM images for three rod samples of dimensions 12x4 nm (Fig. 3A, B), 29x4 nm (Fig. 3C, D), and 60x6 nm (Fig. 3E, F), before and after Au treatment. The presence of the high-contrast tips on the treated rods, forming nano-dumbbells, is evident in all cases. Highly selective tip growth is discerned
5 and demonstrated for three rod sizes and could easily be applied to arbitrary rod sizes. In addition the method was applied to a CdSe tetrapod sample, as can be seen in Fig. 2G showing several tetrapods, and in Fig. 2H showing an enlargement of one tetrapod, following the Au growth process. In this case, the growth occurs selectively on all the tips of the tetrapods leading to a tetrahedral
10 arrangement for the Au tips, and once again providing the natural contact points for this unique structure, for further self-assembly and for electrical connections.

In another example, CdTe nanostructures served as the template for growing various metals on its end portions. The synthesis of the CdTe in different shapes is known [11,14]. In a typical synthesis of CdTe rods, a mixture
15 of 1 mmol of CdO dissolved in 1.125 gr oleic acid and 2.5 gr of 1-octadecene is heated in three neck flask to 300°C to obtain a clear colorless solution. In the glove box, a solution of Te (0.5 mmol of Te is dissolved in 1 ml of TOP) is prepared and brought out in a vial sealed with septum to the injection. After the injection of the Te solution into the mixture in the three necked flask, the mixture
20 is cooled to 260°C for growth. Modification of this procedure in terms of the temperature or precursor concentration results in size and shape changes. The oleic acid is used as a ligand and it dissolves the CdO in the octadecene.

Another specific semiconductor material that may be used is CdS, which is controllable in size and shape. The synthesis is based on the same principle
25 which is injection precursor to hot solution, the Cd and S precursor in this case is Cd(S₂CNET)₂ [12]. In typical synthesis of CdS nanorods, a warm solution of Cd(S₂CNET)₂ (50 mg dissolved in about 0.3 g of hexadecylamine (HDA) at about 70°C) is injected into hot solution of HDA and after 1 hr is cooled to 70°C and treated with ethanol and separated by centrifuging. Controlling the shape of the

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nanocrystals is done by changing the growth temperature of the synthesis from 300°C (rods) to 120°C (tetrapods).

Metal tips by the method described above have also been grown onto CdSe/ZnS core/shell nanorods (29x4 nm rods with 2 monolayer ZnS shell) with initial emission quantum yield of 2% [15]. Treatment of these rods with DDAB and dodecylamine without Au led to an increased quantum yield of 4%, likely because of the effect of the excess amine. Several Au sizes were grown from about 2 nm to about 4.5 nm Au at the tips of the rods.

The metalized structures (in the case of Au growth the formed structures are termed herein "gilded structures") exhibit new and different electronic, electrical and optical properties as compared to the original rods, due to the strong effect of the metal on the semiconductor properties. Absorption and photoluminescence (PL) measurements were carried out to study the effect of Au growth on the rod optical properties as shown in Fig. 4. Absorption spectra (Fig. 15 4A) for the small Au tips on the rods still shows the excitonic structure but with increased absorbance in the visible and the appearance of a tail to the red of the particle gap. Upon increased Au size, the features of the absorption of the rods are washed out and the tail to the red becomes more prominent. The spectra should contain in principle contributions from the semiconductor part and the 20 plasmon resonance associated with the Au tips. However, attempts to add spectra of the rod template and Au nanocrystals did not reproduce the observed absorption and we suggest that the spectra are not a simple sum of both components because of the modified electronic structure of the Au-rod nano-dumbbell system. The strong mixing of the semiconductor and metal electronic 25 states leads to modified density of states exhibiting broadened levels and a reduced band-gap.

The significant coupling of the Au is also observed for the PL (Fig. 4B) that undergoes considerable quenching with increased Au ball size, by a factor of about 100 initially for the smaller Au balls (about 2 nm), and gradually down to a 30 factor of about 500 for the large Au balls (about 4.5 nm). Quenching of the

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emission by the metal end portions is expected via the new non-radiative pathways created by the proximity of metals, likely leading to electron transfer to the Au. Moreover, a systematic dependence of quenching on Au size is seen as shown in the Stern-Volmer type plot (inset of Fig. 4B). Both absorption and 5 emission spectra exemplify the significant effect of the Au on the semiconductor rod properties in this new system, further proving the strong bonding of the Au to the CdSe rod.

The selective tip growth of Au onto the rods and tetrapods not only provides important developments for enabling electrical connectivity and new 10 paths for self-assembly for such nanostructures. It is also an interesting and novel chemical reaction route with clear selectivity and anisotropic character. The reaction mechanism for the gold growth entails a reduction of Au. Examining by TEM the Au solution with DDAB and dodecylamine, already reveals the formation of Au particles. When the reaction is carried out without 15 dodecylamine, considerable aggregation of the CdSe rods was seen (Fig. 6A). Additionally, without the amine, growth of Au on rods was not apparent initially and only after the irradiation under the electron beam of the TEM we could observe some Au growth (Fig. 6B).

One of the benefits of the method of the present invention is its specificity 20 leading to selective tip growth. This results from the preferential adsorption of the metal, e.g. Au complex formed in the Au solution by adding Au salt to DDAB and dodecylamine onto the nanostructures end portions. The tips are more reactive due to the increased surface energy and also possibly due to imperfect passivation of the ligands on these faces, which also leads to 25 preferential growth along the <001> axis of CdSe rods. Once Au nucleates on the end portion, it is preferential for additional Au to adhere and grow on that seed. This gains support from controlling the extent of Au growth on the rod tips by using increased concentration of Au in the gold solution as was shown in Fig. 1. Moreover, early Au growth as shown in Fig. 1B reveals that in some rods

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preferential early growth occurs on one tip, in agreement with the surfactant-controlled growth model suggested for CdSe rods [9].

Under different conditions it is also possible to achieve growth of the metal only on part of the end portions of the nanostructure. Thus, for example,
5 when the nanostructure is in the form of rod, it is possible under suitable
conditions to perform metallization only on one end out of the two end portions
of the rod forming so called 'monobells'. This performance is exemplified in Fig.
9 showing one sided growth of Au on CdSe nanorods of various dimensions: Fig.
9A – 18x3.5nm; Fig. 9B – 25x4nm; Fig. 9C – 50x4nm; Fig. 9D – the same as (C)
10 with different gold tip size.

The route for one-sided growth involves using higher concentration of Au precursor. In a typical one sided Au growth reaction, a gold solution was prepared containing 2.5 mg AuCl₃ (0.008mmol), 20 mg of DDAB (0.04mmol) and 35 mg (0.185mmol) of dodecylamine in 4 ml of toluene and sonicated for 5
15 minutes at room temperature. The solution changed color from dark orange to light yellow. 0.8mg (2.35×10^{-10} moles of rods) of CdSe quantum rods with the size 50X4 nm were dissolved in 20 ml toluene in a three neck flask under argon. In the case of 25X4nm rods size, 0.9 mg (4.8×10^{-10} moles of rods) were dissolved in 20 ml toluene with keeping the same gold solution amounts. The gold solution
20 was added drop-wise over a period of three minutes. During the addition, carried out at room temperature, the color gradually changed to dark brown. In the monobells synthesis (one sided growth) as mentioned here, the mole ratio of Au to nanorods is significantly higher as compared with the nano-dumbbell (two sided growth) case. One sided growth is desirable for some self-assembly
25 schemes and also for different non-linear optical properties such structures may reveal in optical applications. Additionally, a one sided grown structure has intrinsic asymmetry and can serve as a diode element.

It is important to note that in some cases Au growth was identified on branching and defect points, but at slower rate compared to the distinctive tip
30 growth discussed above. This can be seen in Fig. 3E and 3G, where weak dark

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Au spots appear also in some positions other than the tips of the long rods and tetrapods. This growth can be controlled by the amounts of Au added to the rods. At such defect points, such as points where the diameter of the structure changes, there is also increased reactivity due to the imperfect chemical bonding and 5 increased surface energy. This leads to Au adhesion and growth in agreement with the mechanism for tip growth. It is emphasized that the tip growth occurs more readily and rapidly than growth on the defects and hence can be controlled to achieve contact points.

The method may easily be expanded to additional semiconductor 10 nanocrystal systems and to additional metals, to tailor the metal tip contacts as desired and the semiconductor element as well.

One application for the metal tips is in serving as electrical contact points. The role to be played by the Au tips as contact points for wiring the rods is exemplified by conductive atomic force microscopy (C-AFM) measurements 15 carried out on gilded 60x6 nm rods. Rods were deposited onto a conducting highly ordered pyrolytic graphite substrate, and embedded in a thin layer of poly methyl methacrylate (PMMA) to avoid dragging by the tip as reported earlier for regular rods [16]. The current image of a single rod measured by this method reveals that already at a bias of 1.5-2 V, small tunneling current is flowing 20 through the tips which are composed of Au, while the central part of the rod consisting of the semiconductor is non-conductive at these conditions (see Fig. 7). The small tunneling current is determined by the tunneling barriers at tip-nanocrystal and nanocrystal-substrate junctions, dominated primarily by the PMMA. This measurement reveals the significantly higher conductance of the 25 Au tips which would be critical for using them as electrical contact points.

Several strategies can be employed to realize such contacts. It is possible to form the metallized nanorods or other branched structures onto a substrate, identify their position, and then write by electron-beam lithography electrodes to overlap with the Au tips. In a different approach, it is also possible to deposit the 30 metallized rods onto pre-existing electrode structures, with or without

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electrostatic trapping by an applied electric field. Since the metal tipped nanostructures enable the connectivity to electrode structures, this clearly opens the path for using them as transistors, in sensing applications, and in light emitting or light detecting devices.

5 The metal end portions can also impart the rods with advantageous and novel optical properties. They exhibit enhanced linear and non-linear optical properties. The polarizability of such a structure may obviously be significantly increased compared with that of the regular rods. For example, enhancement in second, third and higher harmonic generation and also the observation of novel
10 plasmon resonances related to highly controlled distances that could be tailored for the metal tips on rods.

Additionally, is possible to apply the powerful approach of self assembly by using for example, biological templates e.g. DNA, for creating the connections to the metal tips of nanorods or of branched structures, or
15 bifunctional ligands such as dithiols or diamines for binding preferentially to the Au tips. In such applications the metal tips serve as selective anchor points for ligands and chemistries preferential for the Au surface. Such self assembly could for example be done in solution or onto surfaces. In solution, examples include formation of AAAA chains where A represents rods of one type. This is done by
20 adding bifunctional ligands such as dithiols, for example hexane dithiol, to a solution with gilded nanorods. The preferential binding of thiols to the Au tips leads to chain formation as can be seen in Fig. 8. Another example is the formation of ABAB chains where A represents one rod type and B another rod type. Here biochemical linkers such as avidin-biotin chemistry or DNA linking
25 can be used to make selective ABAB chains. In another approach, combining tetrapods with rods on tip to tip basis may lead to formation of propeller structures.

The same chemistries can be used to self-assemble rods and tetrapods with Au tips onto patterned or non-patterned substrates. For example, a gold or
30 silicon substrate is used together with a bifunctional ligand that binds with one

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function to the substrate and with the second function to the Au tip on the nanostructure.

Metal tipped structures also provide selective metal growth points for additional materials via a seeded growth solution-liquid-solid mechanism.

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